

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No. 09/332,271
Filing Date June 11, 1999
Inventor Klaus Florian Schuegraf et al.
Assignee Micron Technology, Inc.
Group Art Unit 2811
Examiner Unknown
Attorney's Docket No. MI22-532
Title: Methods for Forming Wordlines, Transistor Gates, and Conductive Interconnects, and Wordline, Transistor Gate, and Conductive Interconnect Structures

REQUEST FOR RECONSIDERATION OF PETITION UNDER 37 CFR 1.47(a)

To: Assistant Commissioner for Patents
Washington, D.C. 20231

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REMARKS

The Applicant, Micron Technology, Inc., respectfully requests reconsideration of Petition Under 35 CFR 1.47(a). Examining Attorney Christina T. Tartera lists the requirements for a 35 CFR 1.47(a) petition as: (1) proof that the non-signing inventor cannot be reached or refuses to sign the oath or declaration after having been presented with the application papers; (2) an acceptable oath or declaration in compliance with 35 U.S.C. §115 and §116; (3) the petition fee; and (4) a statement of the last known address of the non-signing inventor. The Examining Attorney Tartera states the Applicant's petition lacks items 1, 2 and 4.